

PATENT NUMBER and ISSUE DATE																				
U.S. UTILITY Patent Application																				
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<p>**APPLICANTS: Park Joohyeon; Seo Dongchul; Lee Jongbum; Jeon Hyunpyo; Kim Seongju;</p>																				
<p>**CONTINUING DATA VERIFIED:</p>																				
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<p>** FOREIGN APPLICATIONS VERIFIED: REPUBLIC OF KOREA 2001-29352 05/28/2001</p>																				
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<small>U.S. DEPT. OF COMM./PAT. & TM-PTO-436L(Rev. 12-94)</small>																				

NOTICE OF ALLOWANCE MAILED		Assistant Examiner		CLAIMS ALLOWED	
ISSUE FEE		Primary Examiner		DRAWING Sheets Drwg. Figs. Drwg. Print Fig.	
Amount Due	Date Paid				
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE		Application Examiner	
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